

OFFICIAL**ATOFINA****Fina Technology, Inc.**15710 JFK Blvd.
Houston, TX 77032P. O. Box 674412
Houston, TX 77267-4412**FAX RECEIVED**
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GROUP 1700**FAX**

To: Jennine Brown	From: Bradley A. Miley
Fax: 703.872.9310	Phone: 281-227-5370
Pages: Including cover sheet (3)	Fax: 281-227-5383
Phone:	Date: 7/22/2003
Re: 09/782,752 discussion points	CC:

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NOT FOR RECORD DISCUSSION POINTS

Fina Technology Inc.

US Patent Application No. 09/782,752

COS-795 Response to First Office Action

Examiner Jennine Brown / James Pasterczyk

In reference to the office action dated May 21, 2003, the following talking points are proposed for your consideration and discussion.

Claim Objections

Amend claims 5, 18, 22, and 29 by replacing the term "method" with "process" in the first line of each claim.

Claim Rejections – 35 USC 103**Sugimura, et al**

Sugimura discloses a low temperature catalyst step at column 53, lines 13-20 and also at column 54, lines 51-59. These steps comprise a compound (b) that is a compound of a transition metal from any of Groups 8 to 10 of the periodic table. See column 47, lines 25-37.

- It is questionable whether a compound of a transition metal from Groups 8 to 10 of the periodic table would be considered a metallocene catalyst as required in the independent claims of the present invention.

Sugimura does not disclose including compound (e), a "fine particulate carrier", in the low temperature catalyst step.

- The present invention requires "a particulate catalyst support material comprising silica particles impregnated with an alumoxane co-catalyst ..." in step (a) of the synthesis.

Sugimura does not teach the percentage of impregnation of the internal pore volume of silica.